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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Sheet 3 of

Complete if Known				
Application Number	09/893,340			
Filing Date	June 26, 2001			
First Named Inventor	Kang, Sien G.			
Art Unit	2813			
Examiner Name	Erik J. Kielin			
Attorney Docket Number	018419-008320US			

OTHER PRIOR ART NON PATENT LITERATURE DOCUMENTS				
Examiner Initials *	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Τ²	
EK	40	Centura Epi "Epitaxial Deposition Chamber Specifications" Brochure, Applied Materials, March 1994.		
EK	41	EPI CENTURA System Specifications Brochure, Applied Materials, October 1996.		
EX	(42)	MAHAJAN et al., Principles of Growth and Processing of Semiconductors, WCB McGraw-Hill, chapter 6, pgs. 262-269.	V	
EK	43	SATO et al., "Suppression of Si Etching during Hydrogen Annealing of Silicon-on-Insulator," <u>Proceedings 1998 IEEE SOI Conference</u> , pgs. 17-18, from conference of 10/5-8/98.		
EK	44)	SMITH, D.L., Thin-Film Deposition, McGraw-Hill, Inc., pgs. 185-196, 278-293.		
EK	(45)	TONG et al., Semiconductor Wafer Bonding: Science and Technology, John Wiley & Sons, Inc., pgs. 152-171.	,	
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Examiner Signature	Erilliely	Date Considered	10/28/03

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¹ Unique citation designation number. 2 Applicant is to place a check mark here if English language Translation is attached.